

Supporting Information

**Photochemical In Situ Elaboration of Polyoxometalate
(α -[SiMo₁₂O₄₀]⁴⁻)/Polymer Hybrid Materials.**

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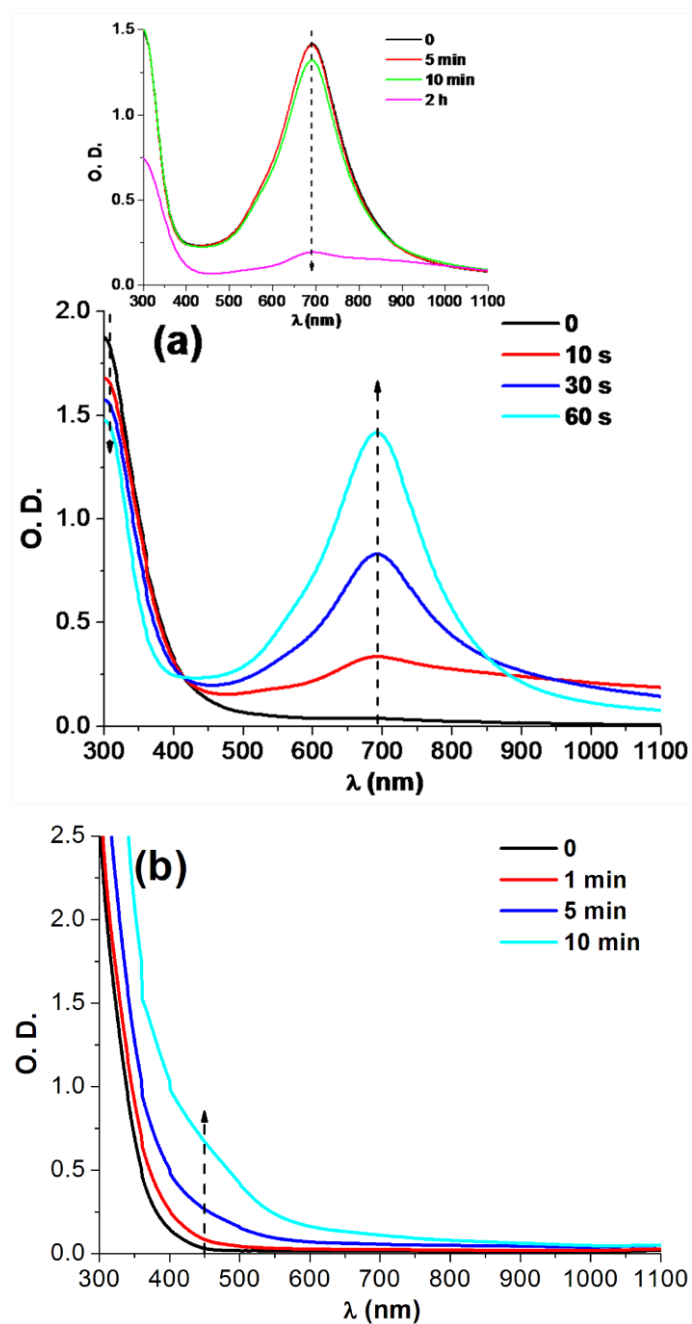


Figure S1. Steady state photolysis of (a) HSiMo12 alone in nitrogen-saturated toluene and (b) HSiMo12/Iod in acetonitrile under air upon the Xe-Hg lamp exposure. Insert: HSiMo12 alone in nitrogen-saturated toluene upon Xe-Hg lamp exposure for 60 s and then exposed to air for different time.

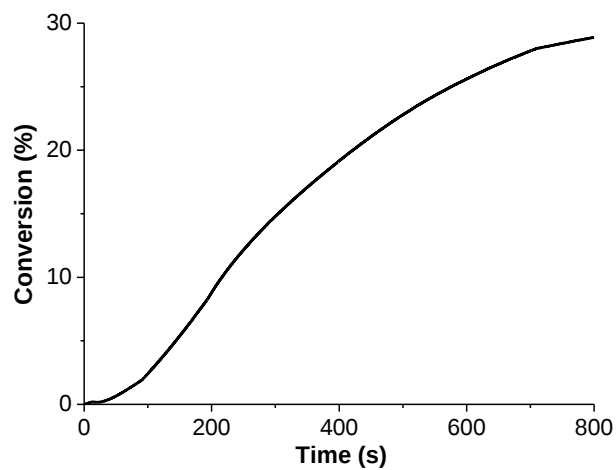


Figure S2. Photopolymerization profile of TMPTA in laminate upon the Xe-Hg lamp exposure in the presence of HSiMo12/Iod (1%/1%, w/w).